TopMap Micro.View®



TopMap Micro.View® is an easy to use and compact optical profiler. Combine exceptional performance and affordability with this powerful metrology solution. This white-light interferometer with an extended 100 mm z measurement range with Continuous Scanning Technology (CST) allows complex topographies to be measured at nm resolution. This convenient table-top setup features integrated electronics, with the smart focus finder simplifying and speeding up the measurement procedure.

Benefit from the optional ECT Environmental Compensation Technology, enabling reliable and accurate measurement results even in noisy and challenging production environments. Micro.View® is the cost-effective quality control instrument for inspecting precision engineered surfaces in the field of manufacturing and research.





Highlights

- Measure surface finish in a compact setup
- Non-contact measurement of 3D topography, roughness and texture
- 100 mm Z measurement range with CST Continuous Scanning Technology
- Excellent lateral resolution
- Determine surface defects
- Choose from application-specific objectives 0.6x – 111x

TopMap Micro.View®

Table-top optical surface profiler Datasheet



Technical data



The information for the optical profiler TopMap Micro.View® (TMS-1400) complies with the *Fair Data Sheet* initiative for optical surface measurement devices. Additional specs are highlighted in blue.

General features							
Working principle	Coherence scanning interferometry						
Nominal vertical measurement range in a single measurement	100 mm						
Positioning range of workpiece ¹	X = 75 mm, Y = 75 mm, Z = 100 mm						
Max. number of measuring points in a single measurement	N _x : 1352; N _y : 1000; N _{xy} : 1352000						
Max. number of measuring points in a stitched measurement	$N_{xy,max} = 500 \text{ million}$						
Surface reflectivity	Works on any surface from shiny to scattering (Reflectivity 100% to 0.05%)						
General specifications							
Dimensions [L x W x H] Stand Sensor head	520 x 575 x 540 mm ³ 270 x 440 x 182 mm ³						
Weight Stand ¹ Sensor head ²	26 kg 12.8 kg						
Recommended temperature range for measurement	20 ±3 °C						
Permissible temperature gradient	1 K/h						
Operation/Storage temperature	+10 °C +35 °C (50 °F 95 °F) / -10 °C +65 °C (14 °F 149 °F)						
Relative humidity	max. 80 %, non-condensing						
Power	100 240 VAC ±10 %, 50/60 Hz, 100 W system + 120 W PC						
Configuration possibilities							
Hardware included	Manual tip-tilt stage, encoded turret, precision Z drive with CST Continous Scanning Technology, integrated vibration isolation						
Hardware options	Objectives, positioning stages: manual xy and motorized xy, advanced Focus Finder, joystick, barcode reader, calibration sets, active vibration isolation breadboard						
Software included	3D data acquisition with multiple operation modes, SST Smart Scanning Technology, 2D/3D data evaluation features, ISO roughness analysis (ISO 25178, ISO 4287, ISO 4288, ISO 21920, ASME B46.1), automation with recipes, easy wizard, pre-scan, critical dimensions						
Software options	ECT Enviromental Compensation Technology, QC Quality Control package, operator interface, pattern matching, software customization, MountainsMap						

¹ With optional XY-positioning stage

² Without objectives

³ Limited by objective working distance and workpiece geometry

⁴ Standard system, height spacers optional

⁵ According to Rayleigh criterion, related to a central wavelength of 525 nm

⁶ Evaluation of the correlogram phase

⁷ Based on DIN EN ISO 25178-700, 30 measurements at 17.2 μ m/sec, on a parallelly aligned plane mirror (R > 93%, λ /10). Postprocessing: levelling, 5 x 5 spike-removal, high pass filter λ c = FoV width/4, no denoising

⁸ According to DIN EN ISO 25178-604:2013-12, 30 measurements at 17.2 μm/s (10x objective) on a parallelly aligned plane mirror (R > 93%, λ/10). Postprocessing: levelling, 3x3 median filter denoising, 5 x 5 spike-removal.

⁹ Repeatability of the individual RMS values from the surface topograhy repeatabilty measurement

 $^{^{10}}$ 15 measurements per step at 17.2 μ m/s, on a calibrated depth setting standard, type KNT 4080/03 (ISO 5436-1), in various sections of the 100 mm nominal vertical measurement range.

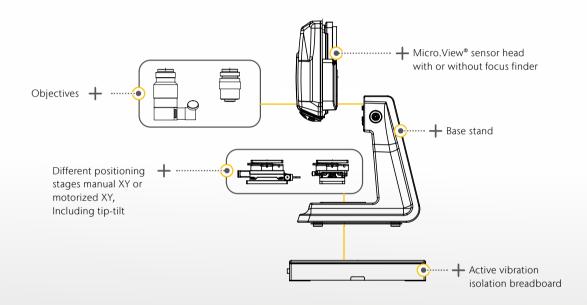
^{11 15} measurements at 17.2 µm/s (4x objective) on a calibrated gauge block of precision class K (contact bonded on an optical flat).

¹² Standard deviation of the measured step height under repeatability conditions

Objective-specific features												
	0.6x	2.5x	5x	10x	20x	50x	100x	111x	4x LWD	10x SLWD		
Measurement area in a single measurement												
X [mm] Y [mm] X · Y [mm²]	13.19 9.76 128.69	3.17 2.34 7.43	1.59 1.17 1.86	0.79 0.58 0.46	0.39 0.29 0.12	0.16 0.12 0.019	0.08 0.06 0.005	0.07 0.05 0.004	1.98 1.47 2.90	0.79 0.58 0.46		
Extended lateral measurement range (stitching) ¹												
Maximum area [mm²] Maximum undirectional length [mm]	5625	5625 2737 684 171 42 6 1 1 1069 171 75										
Working distance [mm]	9.2	10.3	9.3	7.4	4.7	3.4	2	0.7	27	28		
Usable vertical measuring range ³ [mm]	9.2	10.3	9.3	7.4	4.7	3.4	2	0.7	27	8.6		
Maximum workpiece height ⁴ [mm]	22.5	60	100	100	100	100	100	100	42	8.6		
Numerical aperture	0.015	0.075	0.13	0.30	0.40	0.55	0.70	0.80	0.10	0.18		
$\begin{array}{c} \text{Maximum measurable} \\ \text{local slope } \alpha \end{array}$	0.86°	4.30°	7.47°	17.46°	23.58°	33.37°	44.43°	53.10°	5.74°	10.37°		
Measuring point spacing Δ_x/Δ_y [µm]	9.76	2.34	1.17	0.59	0.29	0.12	0.06	0.05	1.47	0.59		
Calculated lateral optical resolution $\delta_L^{\ 5}[\mu m]$	21.35	4.27	2.46	1.07	0.80	0.58	0.46	0.40	3.20	1.78		
Measurement noise $N_{\rm M}$ 6,7	< 0.6 nm											
Digital resolution	0.01 nm											
Surface topography repeatability ^{6,8}	< 0.2 nm											
Repeatability of RMS ⁹	< 0.05 nm											
Maximum deviation of a step height measurement	7.5 μm step: 0.3 μm ¹⁰ 75 μm step: 0.7 μm ¹⁰ 20000 μm step: 5.0 μm ¹¹											
Step height measurement repeatability 12	7.5 μm step: 1.6 % 75 μm step: 0.2 % 20000 μm step: 0.003 %											
Flatness deviation Z_{FLT} 6	< 5 nm											
Flatness measurement repeatability ⁶	< 0.5 nm											
Other features												
Optical setup	Microscope system; Light source: long-life LED, 525 nm											
Data formats	Topography formats: SUR, ASCII, STL, X3P Export formats: qs-STAT, PDF, BMP, PNG, TIFF, GIF											



Configuration of the optical profiler



Shaping the future since 1967

High tech for research and industry. Pioneers. Innovators. Perfectionists.

Find your Polytec representative: www.polytec.com/contact

Polytec GmbH · Germany Polytec-Platz 1-7 · 76337 Waldbronn